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[19]

Urano et al.

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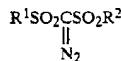
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[57] **ABSTRACT**

wherein R¹ is a C₃₋₈ branched or cyclic alkyl group, and R² is a C₁₋₈ straight-chain, branched or cyclic alkyl group, is effective as a photoacid generator when used in a photoresist material for light of 300 nm or less.

7 Claims, 2 Drawing Sheets

Related U.S. Application Data

[63] Continuation of Ser. No. 646,909, Jan. 28, 1991, abandoned.

[30] Foreign Application Priority Data

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[58] Field of Search 534/556, 558, 565

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